

# **Non-Destructive Terahertz Imaging and Spectroscopy**

Zachary J Thompson

September 2019



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# **Non-Destructive Terahertz Imaging and Spectroscopy**

**Zachary J Thompson**

**September 2019**

**Idaho National Laboratory  
Idaho Falls, Idaho 83415**

**<http://www.inl.gov>**

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# ***Non-Destructive Terahertz Imaging and Spectroscopy***

## **Topics:**

**Nonlinear THz Spectroscopy Using Plasmonic Induced Transparency**

**THz Field Induced Metal-Insulator Transition in Vanadium Dioxide**

**Non-Destructive Evaluation of Microprocessors using THz Radiation**

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## INTRO:

# Introduction

## TOPICS:

# Motivation

## PIT

 $\text{VO}_2$ 

## ICE

## FUTURE

## Research Topics

# Nonlinear THz Spectroscopy Using Plasmonic Induced Transparency

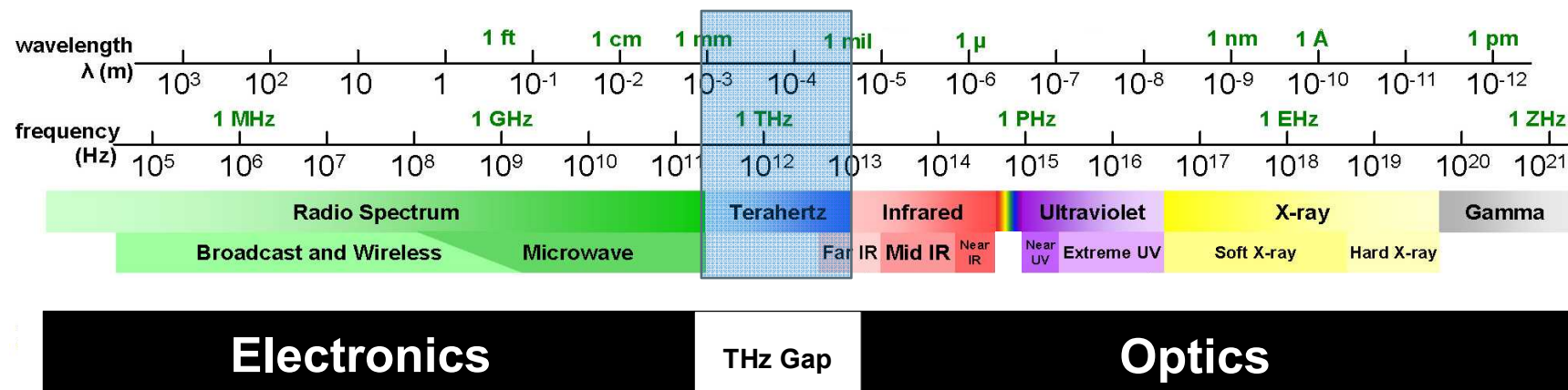
# THz Field Induced Metal-Insulator Transition in Vanadium Dioxide

# Evaluation of Microprocessors using THz Radiation

## Future THz Applications

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# Motivation



- Low energy, Non-ionizing
  - 1 THz photon carries 4.1 meV
  - Generally corresponds to rotations and vibrations of molecules
- Difficult to generate and detect
  - Requires pulsed lasers and/or cryogenic systems
- Relatively unutilized region
  - Table-top sources have only recently been realized

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### PIT

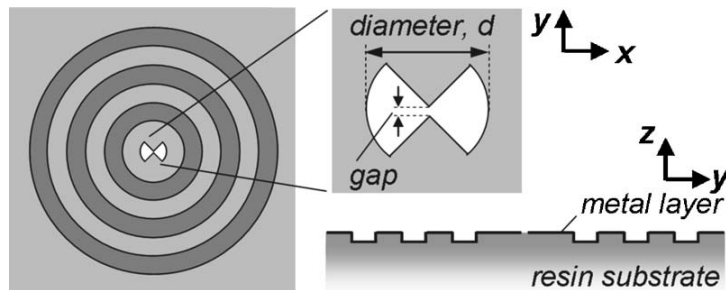
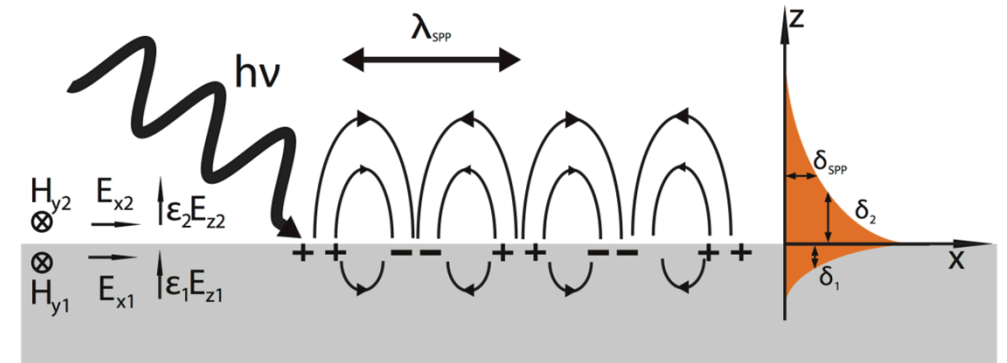
### VO<sub>2</sub>

### ICE

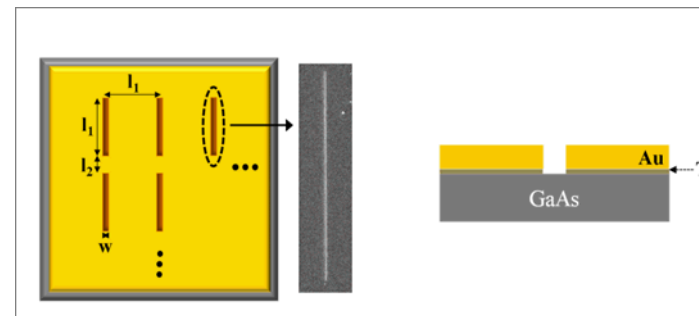
## FUTURE

# Plasmonic Induced Transparency

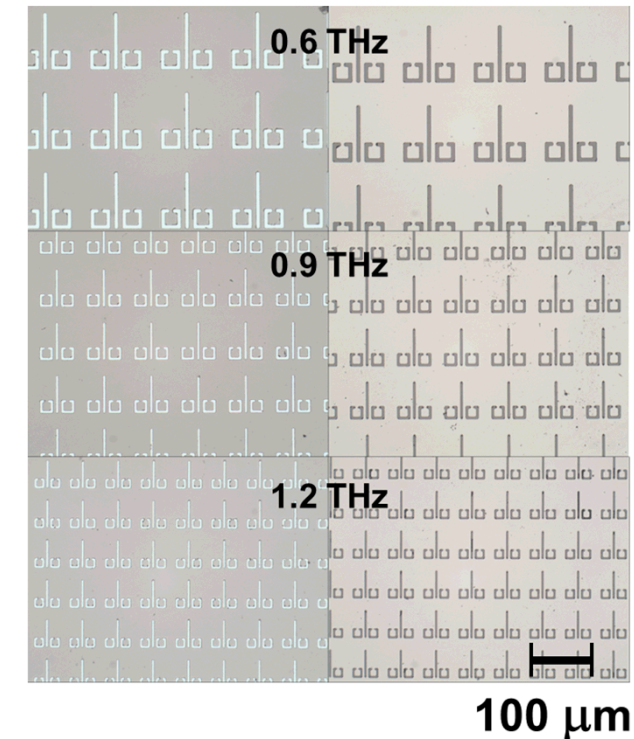
- Plasmonic Metamaterials
  - Sub-diffraction limit imaging
  - Electric field enhancement
  - Plasmonic Induced Transparency



Ishihara et al. APL **89**, 201120 (2006)

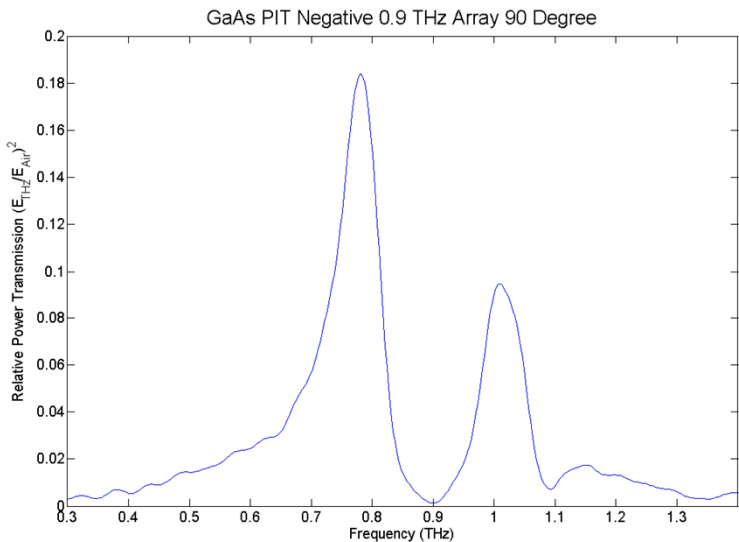
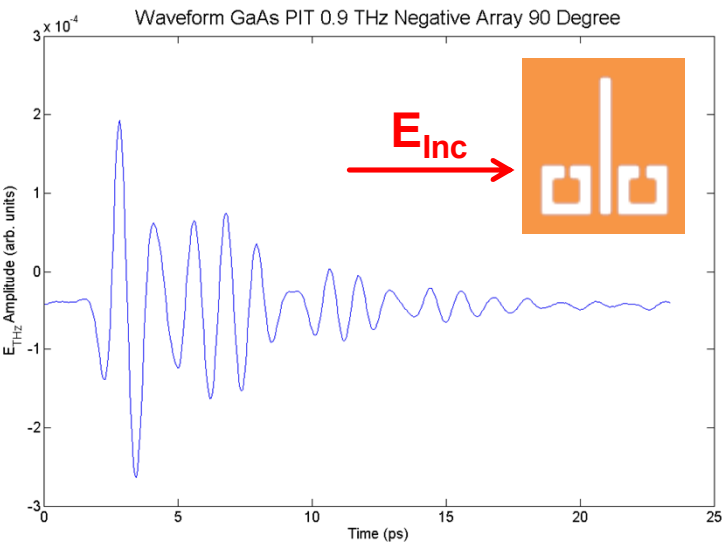
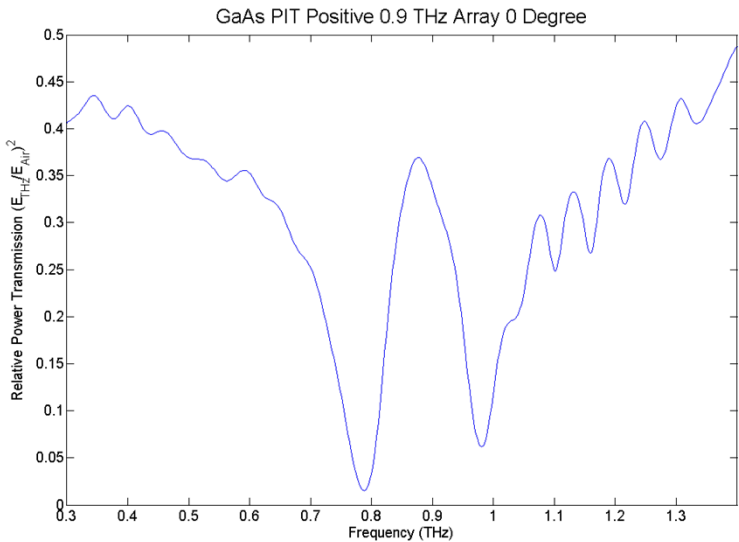
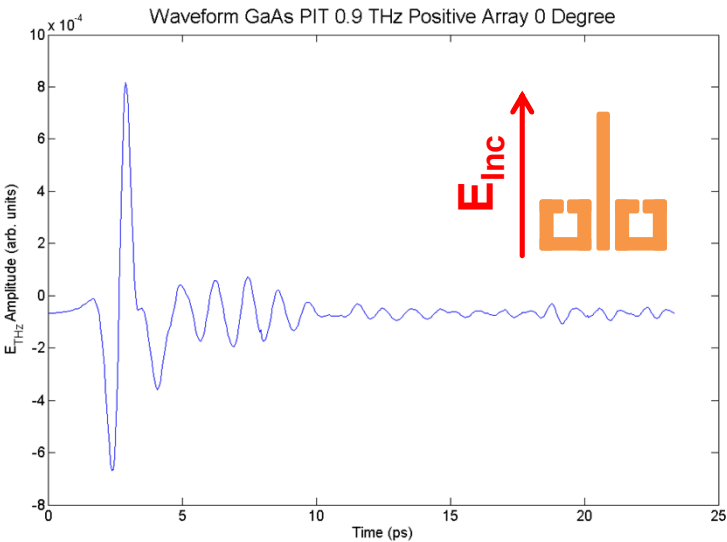


Y. G. Jeong et. al. accepted to CLEO 2013



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# Plasmonic Induced Transparency



## INTRO:

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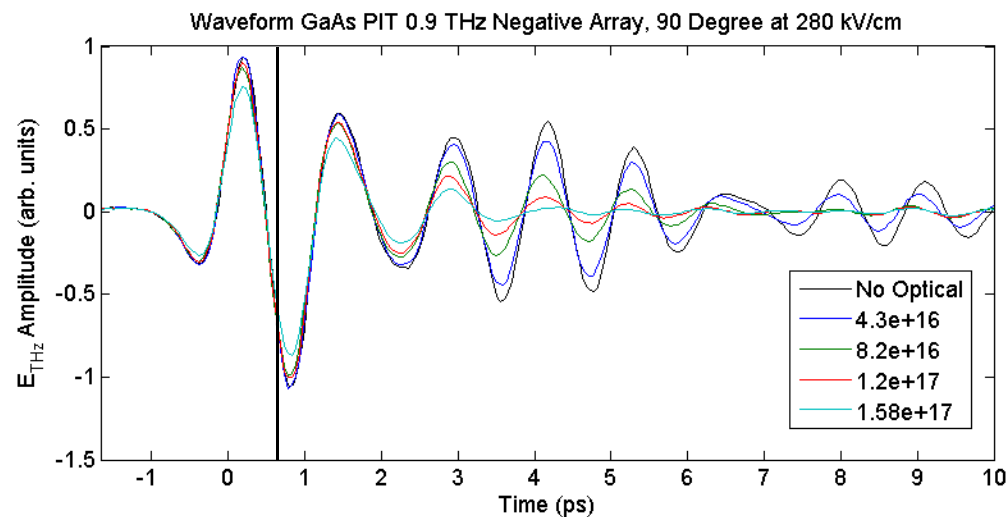
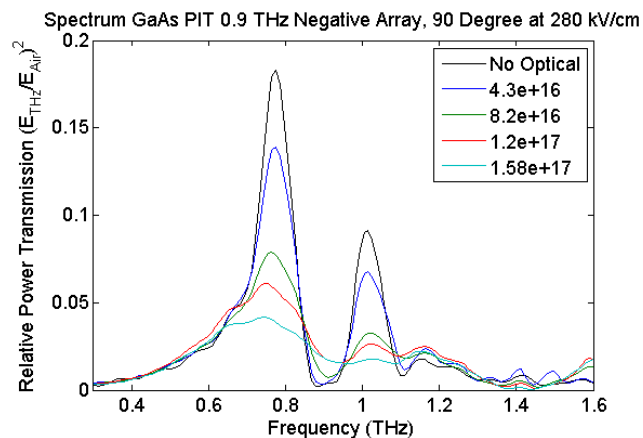
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## FUTURE

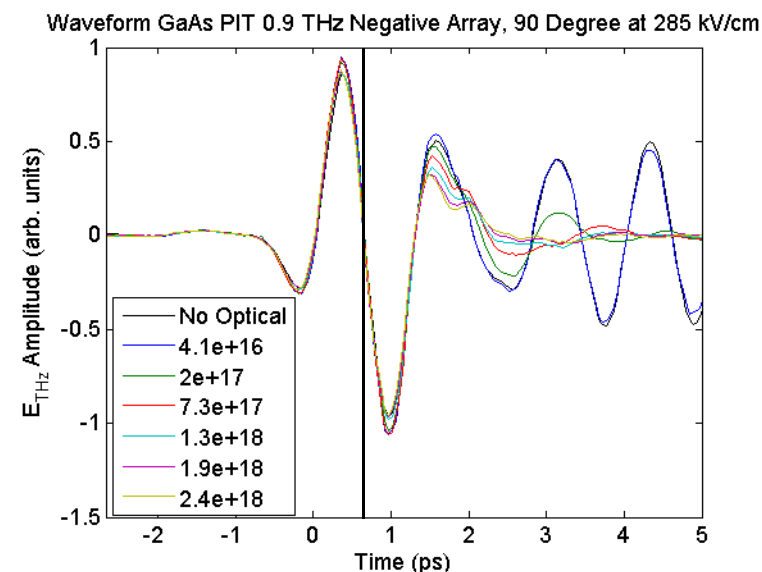
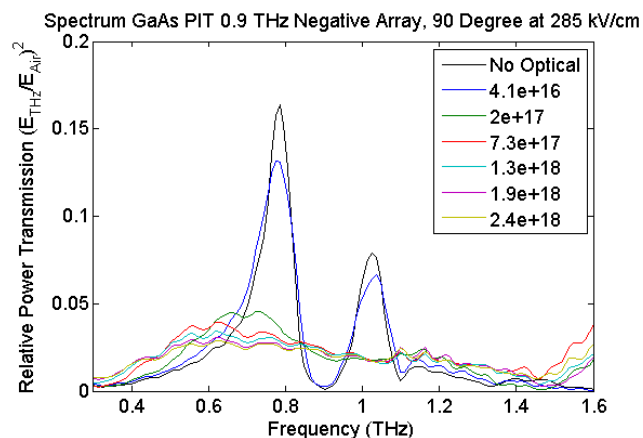
# Plasmonic Induced Transparency

## Optical Excitation

### Low Optical



### High Optical





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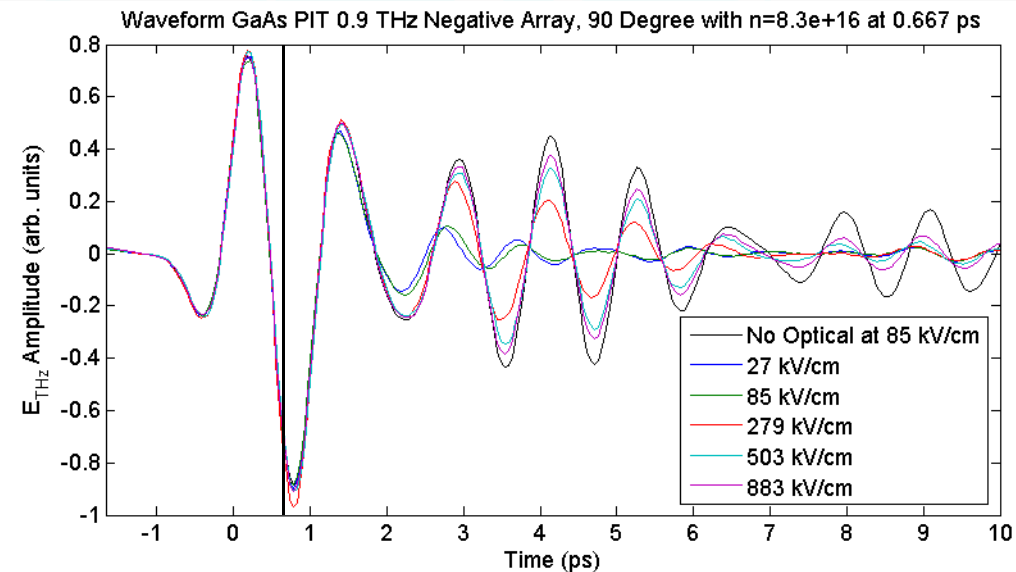
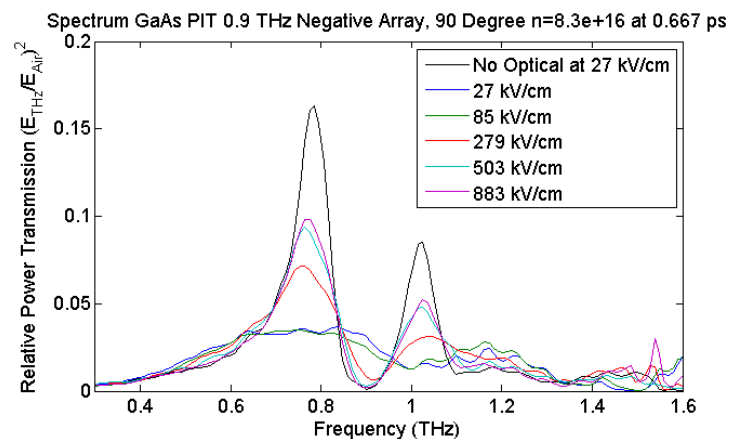
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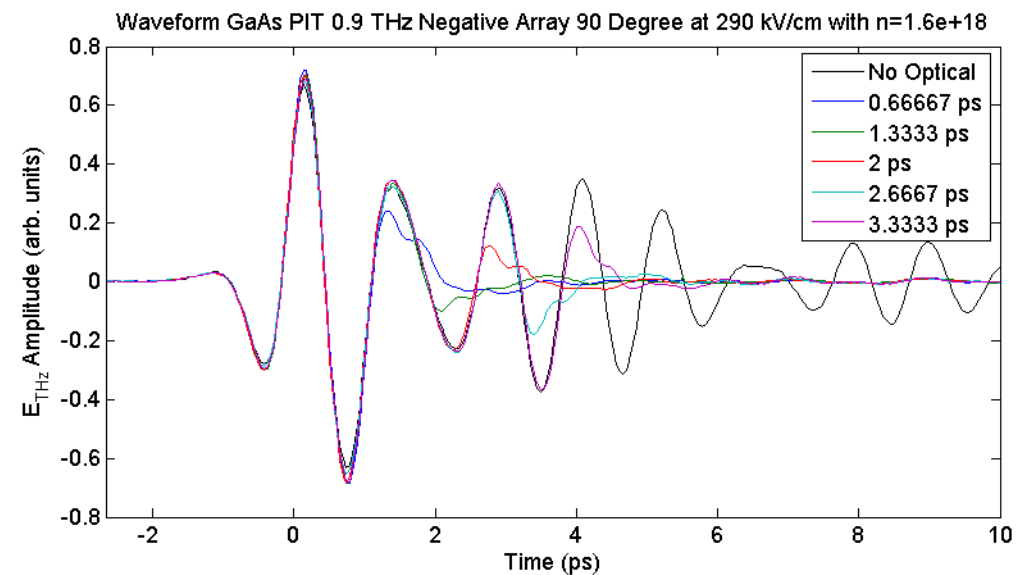
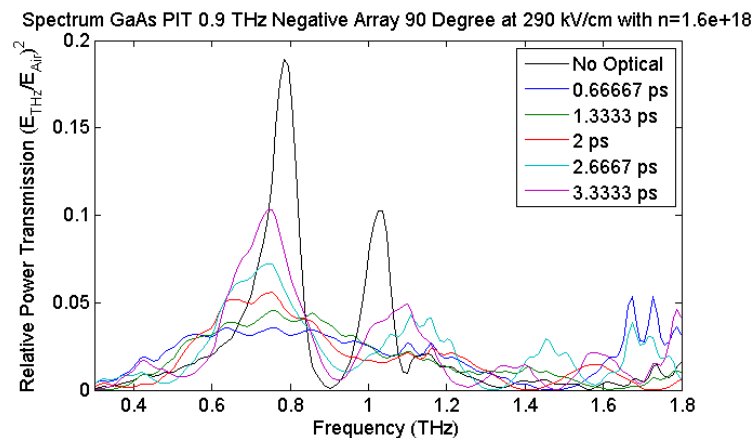
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# Plasmonic Induced Transparency

## THz Control



## Pulse Shaping



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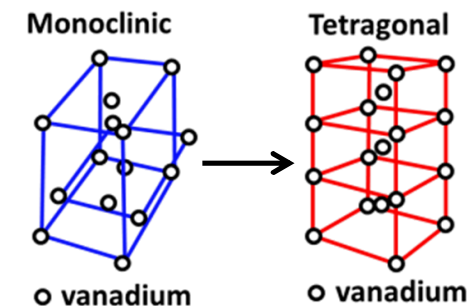
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## Vanadium Dioxide

## Material Properties

- Mott Insulator with Near Room Temperature (343 K) Insulator-to-Metal Transition (IMT)
- Transition can be excited in 2 ways
  - Lattice Distortion
  - Electronic Correlations

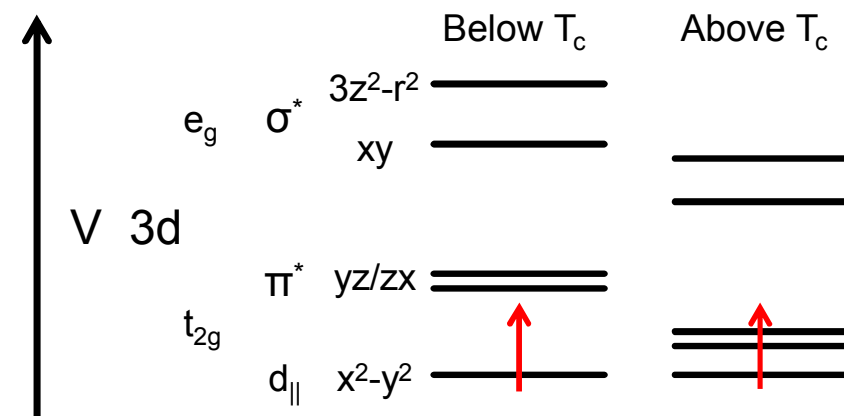


## Mott Insulators

- Conventional band theory assumes independent non-interacting electrons.
- Mott insulators account for electronic correlations.

$$H = - \sum_{\langle ij \rangle, \sigma} t_{ij} (c_{i\sigma}^\dagger c_{j\sigma} + c_{i\sigma} c_{j\sigma}^\dagger) + \sum_{j\sigma} E_j c_{j\sigma}^\dagger c_{j\sigma} + U \sum_i n_{i\uparrow} n_{i\downarrow}$$

## Orbitals for the Equilibrium IMT



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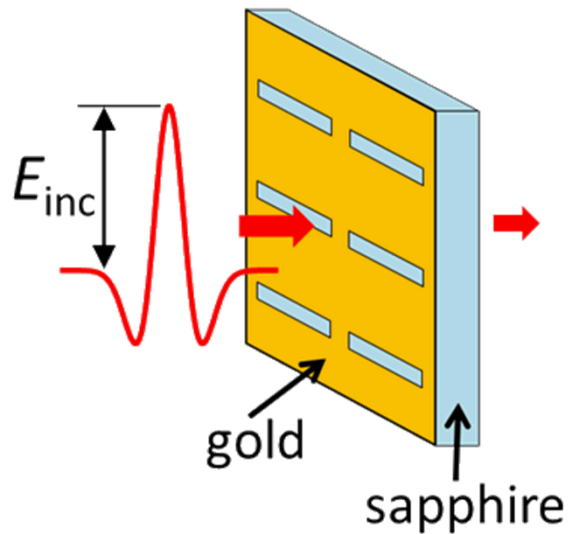
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## Vanadium Dioxide

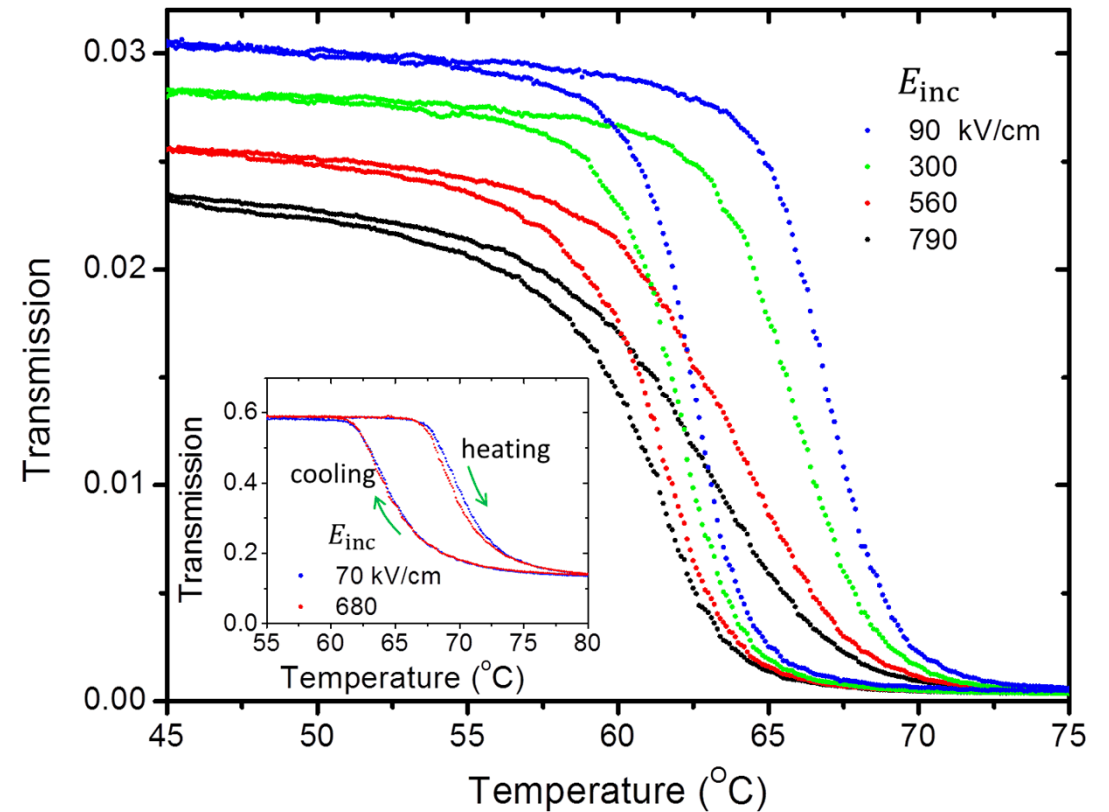
### Sample Structure and THz Field Dependence

#### Nanoslot Sample



$$\alpha = \frac{E_{near}}{E_{inc}} = \frac{1}{\beta} \sqrt{\frac{T}{\tau_r}}$$

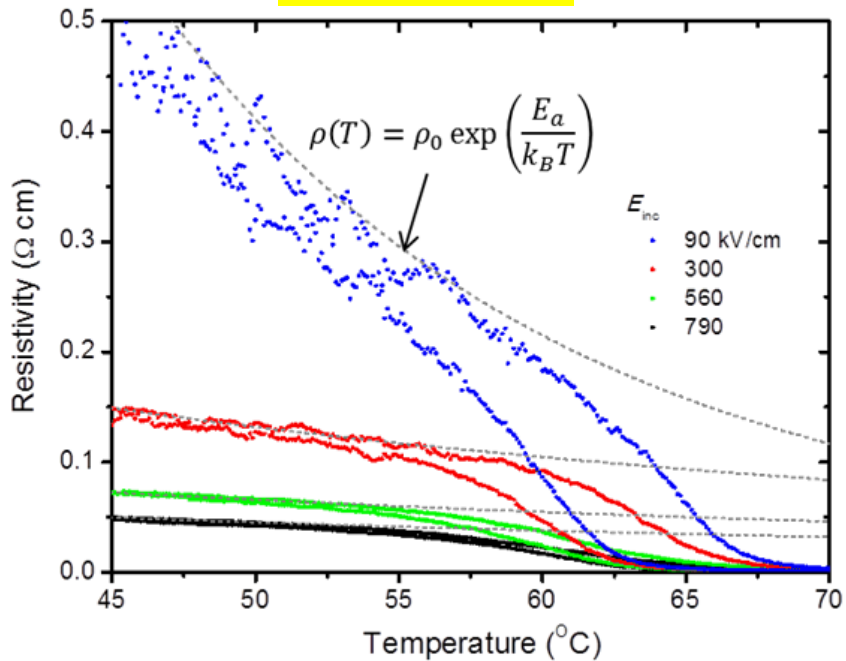
#### Hysteresis



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Vanadium Dioxide

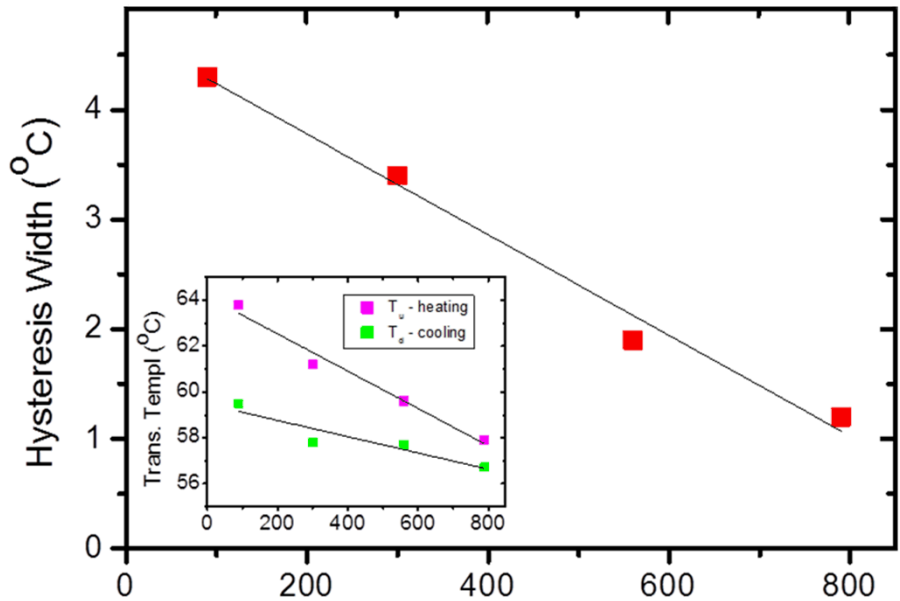
Resistivity



Activation Energy

$E_{THz}$ (kV/cm)	$E_A$ (eV)
90	0.60
300	0.22
560	0.17
790	0.16

Hysteresis Width

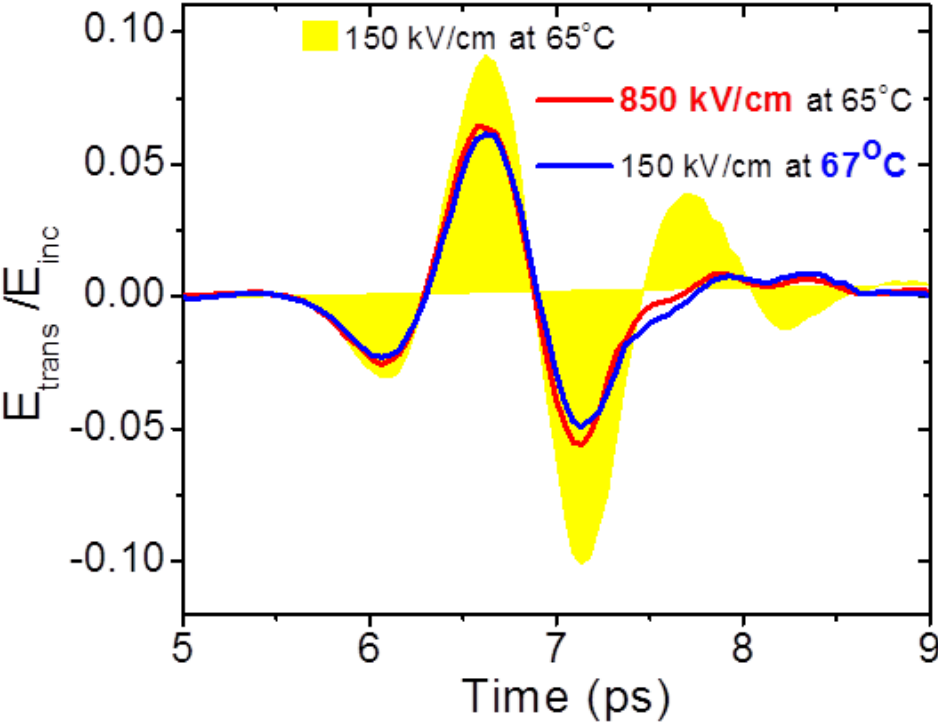


$$\Delta T = T_h - T_c = \frac{\eta G \gamma^2}{2 \Delta S}$$

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*Vanadium Dioxide*

Transient Phase Transition



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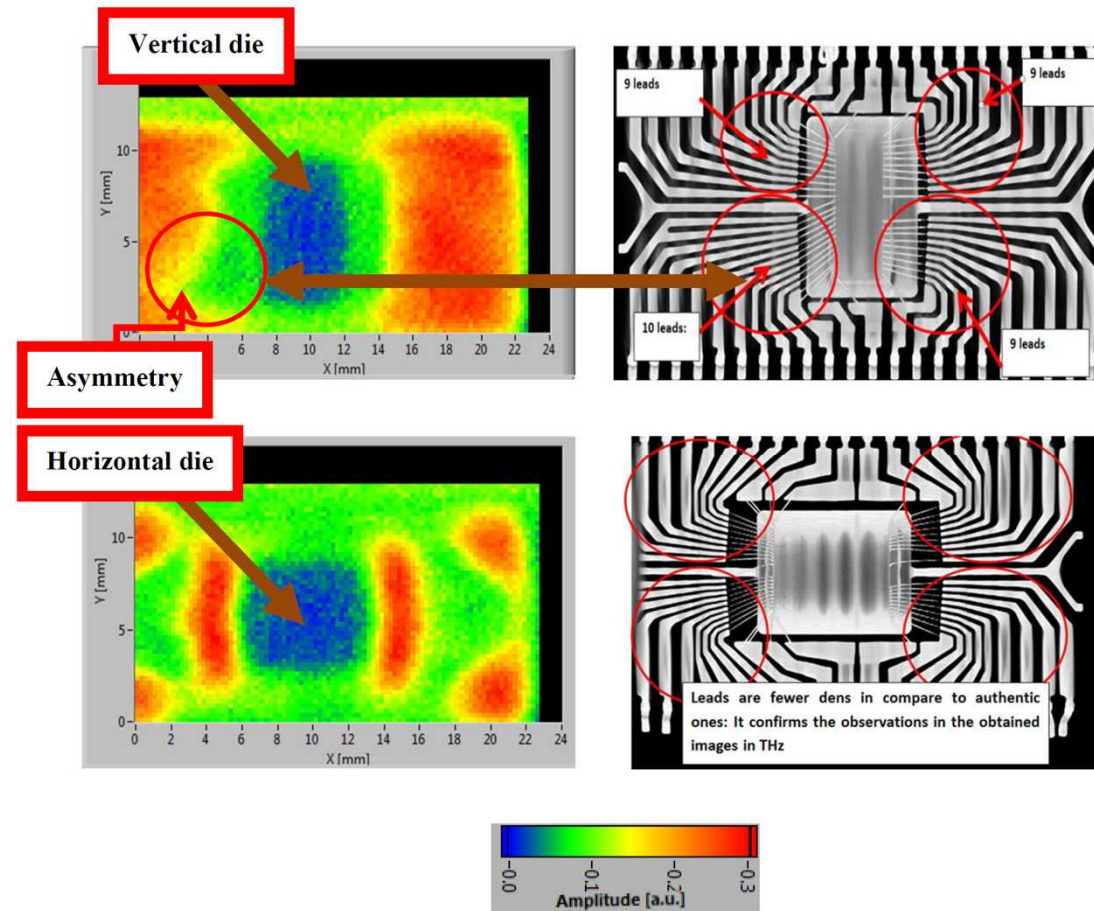
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## Integrated Circuit Evaluation



Ahi, Kiarash, et al. "Terahertz characterization of electronic components and comparison of terahertz imaging with x-ray imaging techniques." *Terahertz Physics, Devices, and Systems IX: Advanced Applications in Industry and Defense*. Vol. 9483. International Society for Optics and Photonics, 2015.



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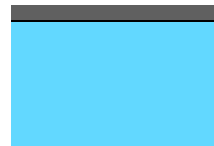
## Future THz Applications

- Material Identification and Characterization
  - Unique Rotational and Vibrational Spectra
  - Non-contact conductivity measurements
  - Possible for direct phonon excitation

Bare  
Graphene

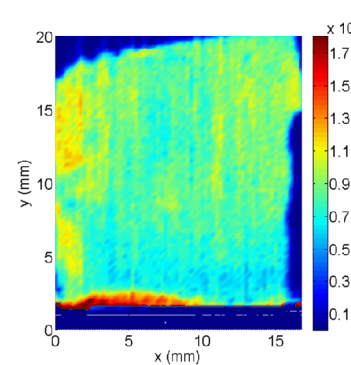


PMMA  
Covered  
Graphene

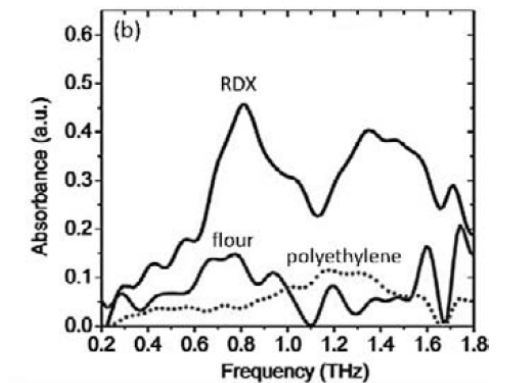
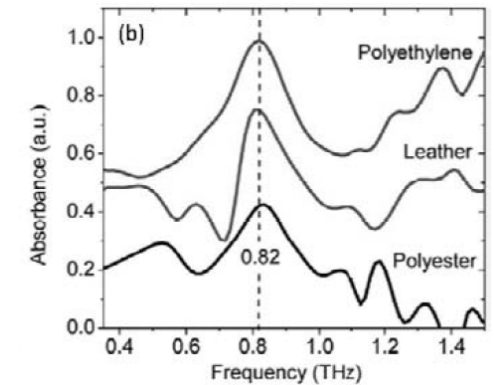
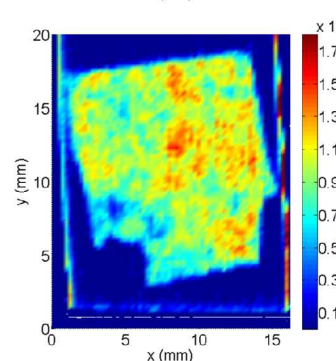
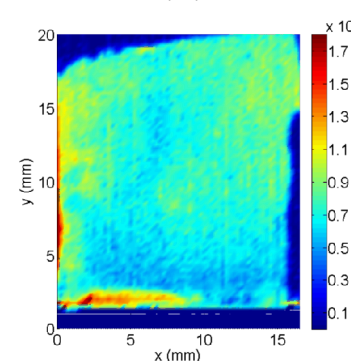
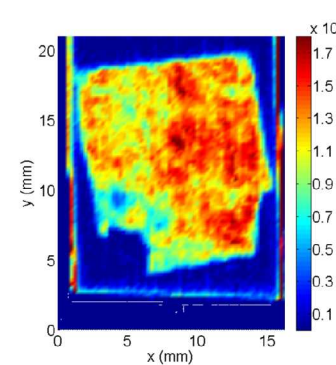


Sheet Conductivity ( $\Omega^{-1}\text{m}^{-1}$ )

Standard growth

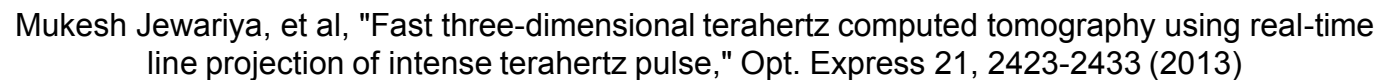


Enclosed growth



Lee *Principles of Terahertz Science and Technology*

- Non-ionizing imaging
  - Computed tomography





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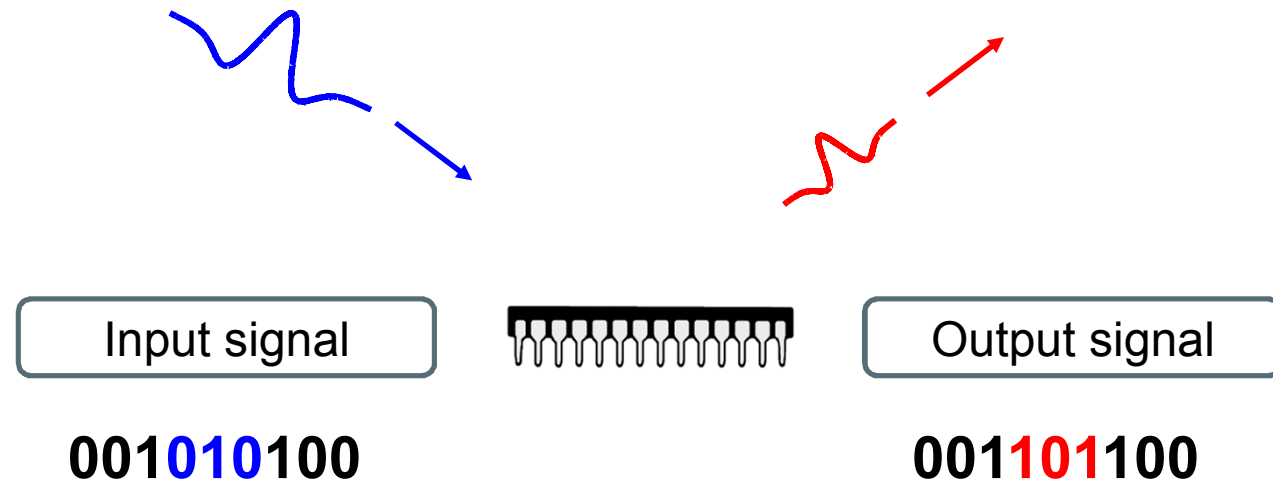
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**FUTURE***Future THz Applications*

- High-Speed, Secure Wireless Communication
  - Bandwidth scales with frequency
  - Low photon energy makes it difficult to detect
  - Highly directional
- Cybersecurity
  - Side Channel Analysis
  - Functional Imaging
  - Code Injection



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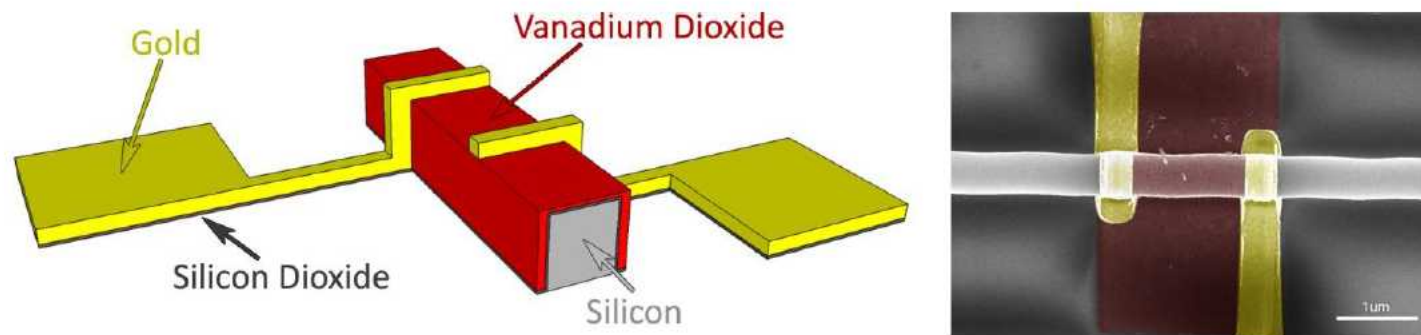
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## *Future THz Applications*

- Highspeed optical switching using metamaterials



P. Markov, et al, "Silicon-VO<sub>2</sub> hybrid electro-optic modulator," *CLEO: 2013*, San Jose, CA, 2013, pp. 1-2.

- Manipulation of entangled quantum systems
  - Nitrogen vacancy centers in diamond
  - Inorganic quantum well systems (GaAs/AlGaAs, etc.)

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## Questions?

- Contact Information
- Zachary.Thompson@inl.gov
- Office: 208-526-9712
- Cell: 907-231-1421